

Amendments to the Specification:

Please amend paragraph [0015] as follows:

[0015] Embodiments of the present invention may include any features described in U.S. ~~patent application 10/613,217, Patent Application No. —/—, —,~~ filed on the same day as the present patent application, entitled “Apparatus and Method for Fabrication of Nanostructures Using Decoupled Heating of Constituents”, ~~attorney docket number ATO-002.00,~~ which is hereby incorporated by reference in its entirety for all purposes.

Please amend paragraph [0031] as follows:

[0031] Several embodiments of the present invention have been discussed. Many of these methods are especially applicable to the integration of nanostructures into devices, and in particular the methods and apparatus of achieving large scaled fabrication of nanostructure-based electronic and electromechanical devices in a reliable and controlled way. For example, the apparatus and methodology can be used on a workpiece on which conventional electronic devices have already been fabricated, and onto which nanostructure-based electronics are to be integrated. The particular fabrication protocols and parameters to be used may be selected, depending on the particular nanostructures sought to be produced. For example, the feedstock delivery system is compatible with various gas precursors to nanotubes, nanowires, and nanostructures, as well as nonreactive gases and carrier gases. For example, Alexandrescu 2003 (R. Alexandrescu et al., “Synthesis of Carbon Nanotubes by CO₂-Laser-Assisted Chemical Vapor Deposition,” *Infrared Physics and Technology*, Vol. 44, 2003, pp. 43–50) and Rohmund 2002 (F. Rohmund et al., “Carbon Nanotube Films Grown by Laser-Assisted Chemical Vapor Deposition,” *Journal of Vacuum Science and Technology B*, Vol. 20, 2002, pp. 803–811) describe particular examples of production of nanostructures; embodiments of the present invention can adapt parameters to replicate the production described in Alexandrescu 2003 and Rohmund 2002, which are hereby incorporated by reference in their entirety for all purposes.